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PATENT & TRADEMARK OFFICE

**PATENT**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Application No. : 10/696,432 Confirmation No. 6825  
Applicant : Ying-Lang Wang  
Filed : October 29, 2003  
TC/A.U. : 2813

Title : **CMP Process Leaving No Residual Oxide Layer or Slurry Particles**

Docket No. : N1085-90131 (TS01-167CB)  
Customer No. : 08933

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**CERTIFICATE OF MAILING,**  
**37 C.F.R. §1.8(a)**

I certify that this correspondence and the enclosures mentioned therein are being deposited by First Class U.S. Mail with sufficient postage on the date shown below, addressed to Commissioner for Patents, PO Box 1450, Alexandria, Virginia 22313-1450.

*Richard A. Paikoff*  
Richard A. Paikoff, Reg. No. 34,892  
11-6-03  
Date

**AMENDMENT AND RESPONSE**

Sir:

In response to the Office Action of December 28, 2004, please amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks** begin on page 4 of this paper.